12/19/18

# CITY OF ELKHART, INDIANA INDUSTRIAL WASTE QUESTIONNAIRE

SEC	TION A.	GENERAL INFORM	ATION (Type or Prin	nt, Please)	
				) _	
2.	Mailing	Address	P.O. Box 280	)	
3.	Address	of Premises	1101 Lafayet	te Street	-
4.	Name an	d Title of Sign	ing Official	George B. Bucklen,	<u> reasurer</u>
5.	Wastewa	ter discharges	to:		
	City se	wer system <u>X</u>	· ·		
	Private	septic system			
6.	If your of disc	•	arges to the City :	sewer system, check the t	ypes
	X	Sanitary	Wash water	Rinse water	
	X	Cooling water	Process wate	er Scrubber wat	er
		Other			
	and not	to the City se ged to the Ci tion A of this	wer system, or if ty sewer system, i	to a private septic sy only sanitary sewage t is only necessary to therwise, complete ent	e is fill
7.	Contact	Official			
	Na	meG	eorge B. Bucklen	or the programme or a manifest to the second of the second	
	Ti	tle <u>T</u>	reasurer		•
	Ad	dress P	.O. Box 280		
	Ph	one Number2	64-1116		
	me and	formation cont to the best of e, complete, and	my knowledge and	estionnaire is familia belief, such informa	r to tion
			12- 29-87	Ann B Buck	2/
			Date	Signature of Offici	al

## SECTION B. PRODUCT OR SERVICE INFORMATION

	MANUFACTURING
	<del></del>
	Deinsing Der Makanisla Hard.
	Principal Raw Materials Used:
-	GLASS AND METAL
-	
	Catalysts, Intermediates:
	N.A.
	N.A.
	Principal Product or Service (use Standard Industrial Classification
	Manual if appropriate): FABRICATION
	Appended to this questionnaire is a list of Standard Industria Classification (SIC) codes for industries currently or potentiall
	subject to USEPA preteatment regulations. List SIC codes fo each of your processes that are subject to USEPA pretreatmen regulations.
	1 C G G L G C L G C C C C C C C C C C C C

1	1. Type of Discharge: Batch Continuous X Both
	For batch discharges, list types, average number of batches/24 hrs.
	and volume (gallons) per batch. 120 gal. per month
2	2. Is there a scheduled shutdown? NO
	When?
3	3. Is production seasonal? NO
•	
	If yes, explain indicating months(s) of peak production.
	4. Average number of employees per shift: 50 lst; 2nd; 3rd
	The first terms of employees per share.
-	5. Shift start times: 7:00 a.m.1st; 2nd; 3rd
6	6. Shifts normally worked each day of the week:
	Sun Mon Tue Wed Thu Fri Sat
	1st <u>X X X X X X</u>
	2nd
	3rd
-	7. Describe any wastewater treatment equipment or processes in use:
	Neutralize metal cleaners in batch tank

## SECTION D. WATER CONSUMPTION AND LOSS

Source			Quantity			
City Syste	em		3465	gallor	s per	da
				gallor	s per	da
				gallor	s per	da
				gallon	s per	da
Water treatment	processes in u	ıse: N/A				
Chemical polymers	coagulation,	including	use of a	lum, ferri	.c chlo	ri
Lime sof	tening					
			-:			
Resin (i	on exchange) v	vater solte	ning			
Resin (i		vater solle	ning			
Filtrati				n		
Filtrati	on	ozone) dis	infectio	•		
Filtrati	on (chlorine or	ozone) dis	infectio	•		
Filtrati	on (chlorine or	ozone) dis	infectio	•		
Filtrati	on (chlorine or	ozone) dis	infection	•		
FiltratiChemicalOthers	on (chlorine or	ozone) dis	infection	•	per da	
Filtrati Chemical Others List Water Consu	on (chlorine or	ozone) dis	infection			-
Filtrati Chemical Others  List Water Consu	con (chlorine or	ozone) dis	infection	gallons p	er da	. <b>y</b>
FiltratiChemicalOthers  List Water Consu Cooling Water Boiler Feed	on (chlorine or mption in Plan	ozone) dis	infection	gallons p	er da er da	.у .у
FiltratiChemicalOthers  List Water Consu Cooling Water Boiler Feed Process Water	con (chlorine or more or more or	ozone) dis	infection	gallons p gallons p	oer da oer da	y y

4.	List average	volume of discharge	e or water loss	to:	
	City Wast	ewater Sewer	3465	gallons	per day
	Septic Ta	nk Discharge		gallons	per day
	Surface D	ischarge		gallons	perday
	Waste Hau	ler		gallons	per day
	Evaporati	on		gallons	per day
	Contained	in Product		gallons	per day
5.	Is Discharge	to Sewer: X	Intermittent	<del></del>	Steady
<b>5</b> .	List averag B-5 above:	e water usage for	SIC Processes	itemized	l in Section
	Regulated SIC No.	Brief Process De	escription		nge Water
	-	N/A			
			4		

### SECTION E. SEWER CONNECTION AND DISCHARGE INFORMATION

Reference No.	Descriptive Location of Sewer Connection or Discharge Point	Av F1 (g
	Three lines exit buildings	
		ndgeren die een de verlande de
and the delice to the second of the STATE		
•••		***************************************
complex showi location of the of monitoring of for sewers and monitoring streference and other pertinent	ed drawing or dimensioned sketch on location of sewer referenced in SIC process described in Section D-manhole, if any, and other possible SIC process effluents. Indicate how aff can gain access to the samplifield orientation buildings, street physical structures should be included	n E-l above -5. Show loca sampling poor City indust ng points. eets, alleys, ided. N/A
	red to prepare a Spill Prevention Com Plan per 40 CFR 112 or a RCRA Con	

#### SECTION F. PRIORITY POLLUTANT INFORMATION

1. Please indicate by placing an "X" in the appropriate box by each listed chemical whether it is Suspected to be Absent, Known to be Absent, Suspected to be Present, or Known to be Present in your manufacturing or service activity or generated as a byproduct. Some compounds are known by other names. Please refer to Appendix A for those compounds which have an asterisk(\*).

		۵	***************************************	9				18.		<u>e</u> .		_
TEM NO.	CHEMICAL COMPOUND	SUSPECTED ABSENT	KNOWN	SUSPECTED PRESENT	KNOWN	ITEM NO.	CHEMICAL COMPOUND	SUSPECTED	KNOWN	SUSPECTED	NNONN	PRISINT
1.	ammonia	X				47.	chlorobenzene	Х				
2.	asbestos (fibrous)	X				48.	chloroethane"	X	1		7	
5.	cvanide (total)	X			1	49.	2-chloroethylvinyl ether			1		
1						50.	chloroform"	X		1	-	_
1.	antimony (total)	Х				51.	chloromethane*	X	1	1	$\top$	
5.	arsenic (total)	X				52.	2-chloronaphthalene	Х		1	_	_
5.	bervllium (total)	X.			1	53.	2-chlorophenol*	X	1	1	_	-
- = -	cadmium (total)			1		54.	4-chlorophenylphenyl the			i	_	_
3.	chromium (total)	X X		_	1	55.	chrysene*	X		1	1	_
٩.	copper (total)	-			1	56.	4,4'-000"		i	i	+	-
10.	lead (total)	X X	1		ĺ	57.	4,4'-DDE*	X	1	i	+-	_
11.	mercury (total)	X		Ī		58.	4,4'-DDT*	x	i	1	7	-
12.	nickel (total)	X	1		<del></del>	59.	dibenzo(a,h)anthracene*	X	i	1	1	_
13.	selenium (total)	Х			<del></del>	60.	dibromochloromethane*	Х	ī	,		_
14.	silver (total)	X		1	i	61.	1.2-dichlorobenzene*	X	1	ī	1	_
!5.	thallium (total)	X	;	ļ	i	62.	1.3-dichlorobenzene*	l X	!	<del></del>		_
16.	zinc (total)	X .			i	65.	1,1-dichlorobenzene*	X	i	1	$\neg$	_
				+	1	64.	3.3'-dichloropenzidine	X	1	1	1	
1	acenaphthene	Х		1	1	1 65.	dichlorodifluoromethane		1		1	
13.	acenaphthylene	X	<del>                                     </del>	1	<del>                                     </del>	66.	1,1-dichloroethane*	Х	÷ ·	i	+	-
19.	lacrolein	X		<del>                                     </del>	<del></del>	1 67.	11,2-dichloroethane*	x	7	1		_
20.	acrylonitrile	y Y	İ	+	<del></del>	68.	l, l-dichloroethene"	T <sub>Y</sub>		1	一	_
21.	aldrin	Y	T	T	1	69.	trans-1,2-dichloroethene		i	1	$\top$	_
33.	anthracene	Ŷ		1	Ť	70.	2,4-dichlorophenol	T <sub>X</sub>	i	1	o	_
23.	beniene	X	-	1	<del></del>	1.	1,2-dichloropropane"	X	Ť	<del></del>	+	_
24.	benzidine	X	Ì	T	1	72.	(cis & trans)1,3-dichlo-		Ť	1	$\top$	_
25.	benzo(a)anthracene*	v		1			ropropene"	X	†			
26.	benzo(a)pyrene*	X	<del>                                     </del>	Ť		73.	dieldrin	Х	7	1	1	_
3	benzo(b)fluoranthene	X	1	+	<del>-j</del>	74.	diethyl phthalate*	X	;	-	1	_
28.	benzo(g,h,i)perylene*	Х	<del>                                     </del>		<del></del>	75.	2,4-dimethylphenol*	X		; .	+	_
29.	benzo(k)fluoranthene*	X	<u> </u>	†	1	76.	dimethyl phthalate	X	;	1	+-	_
30.	a-BHC (alpha)	X	<del>-</del>	Ť	<del></del>	1	di-n-butvl onthalate	X	1	,	+	_
31.	15-8HC (beta)	X		<del>-</del>		78.	di-n-octvl phthalate*	X	<del></del>	1		
32.	d-BHC (delta)	X	}	<del></del>		79.	4.6-dinitro-2-methylphenol		i	1	_	-
33.	g-BHC*(gamma)	x	1	7		1 80.	2.4-dinitrophenol	X	!		<del></del>	_
54.	bis(2-chloroethy)ether		1	1		1 31.	2,4-dinitrotoluene	l X	1	1	_	_
35.	bis2-chloroethoxymethans		1		<del></del>	1 82.	2.5-dinitrotoluene	- · ·	+	<del></del> -	<del></del>	
36.	bis2-chlomisopropylethe		1	<del></del>		1 83.	1,2-diphenylhydrazine*	y	•		$\dashv$	_
37.	bis (chloromethyl)ether*	·		<del></del>		34.	endosultan I*	. X		<del></del>	+	_
38.		1 x	1	<del></del>		1 35.	endosulfan II*	X	_	+	+	-
<u> 59.</u>	bromodichloromethane"	X	T	<del></del>		36.	endosulfan sulfate	: X		i	1	_
10.	bromotorm*	v	1			87.	endrin	÷ A		<del></del>	<del>-</del> †-	_
±1.	bromomethane*	Ÿ	1	+	<del> </del>	188.	endrin aldehyde	X		<del></del>	$\dashv$	
12.	4-bromophenylphenyl euz		<del>                                     </del>	<u> </u>		89.	ethylbeniene	I y		<del></del>	+	
43.	butylbenzyl phthalate	X	<del>                                     </del>	+-	<del></del>	90.	fluoranthene	X		<del></del>		
44.	carbon tetrachloride*		+	+-	<del>-                                    </del>	1 91.	fluorene*			<del></del>	<del></del>	_
15.	chlordane	X X	<del> </del>	+-	+	92.	heptachlor	<u> </u>	+	<del>-                                    </del>		-
-5.	H-chloro-3-methylphenol		+	<del>-</del>		1 93.	heptachlor epoxide	X	٠			_

SECTION F. PRIORITY POLLUTANT INFORMATION (CON'T)

ITEM NO.	CHEMICAL COMPOUND	115	KNOMN	SUSPECTED	KNOWN	PRESENT	ITEM NO.	CHEMICAL COMPOUND	SUSPECTED	KNOWN	SUSPECTED	KNOWN	·
94.	hexachlorobenzene*	Х		-			112.	PCB-1248*	X				
95.	hexachlorobutadiene	Х		1			113.	PCB-1254*	X				]
96.	hexachlorocyclopenta-	Х		L	I		114.	PCB-1260*	X				]
	diene*	X			$oxed{\Box}$		115.	pentachlorophenol	i x	!			]
97.	hexachloroethane*	Y			I		116.	phenanthrene	l v				]
98.	indeno(1,2,3-cd)pyrene*	X			$oxed{oxed}$		117.	phenol	X				]
99.	isophorone*	X			$\Box$		118.	pyrene	X				]
100.	methylene chloride*				$\perp$	X	119.	2,3,7,8-tetrachlorodi-	l y				]
101.	naphthalene	_X_						benzo-p-dioxin*	Y				
102.	nitrobenzene	X.					120.	1122-tetrachloroethane*	<del>  }</del>				_
103.	2-nitrophenol*	y			$\Box$		121.	tetrachloroethene*				X	
104.	4-nitrophenol*	y					122.	toluene*	l x				
105.	n-nitrosodimethylamine*	х					123.	toxaphene	X				
106.	n-nitrosodipropylamine*	X_		L			124.	1,2,4-trichlorobenzene	×		1		1
107.	n-nitrosodiphenylamine*	X					125.	Lil-trichloroethane*	X				
108.	PCB-1016*	У					126.	1,1,2-trichloroethane*	X				
109.	PCB-1221*	x		<u> </u>			127.	trichloroethene*	1 -				
110.	PC3-1232*	У					128.	trichlorofluoromethane	v				١
. 111.	I PCB-1242*	X			$\perp$		129.	2,4,6-trichlorophenol	Y X				
	1						130.	vinyl chloride*	2	1			1

2. For chemical compounds in F-2 above which are indicated to be "Known Present," please list and provide the following data for each: (attach additional sheets if needed).

ITEM NO.	CHEMICAL	COMPOUND		ESTIMATED LOSS TO SEWER LBS:/YR,	ITEM NO.	CHEMICAL CO	MPOUND	ANNUAL USAGE(LBS)	ESTINATED LOSS TO SEWER LBS./YR.
100	MC	٠.	N/A	0	:	_			
121	Perk		N/A	U	;	<u> </u>	1		
								<del></del>	<u> </u>
-			!						<u> </u>
-					1				
	5.								,
					·				1
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	MURIATIC ACID, FORMALDEHYDE, CHOMIC ACID
· · · · · · · · · · · · · · · · · · ·	DIVERSEY-EVERITE, DIVERSEY 656
n proces ere sam ype of s	e, what if any, laboratory analyses have been conducted as waste streams in the plant, including which streams upled, what parameters were measured, and frequency and samples. (The baseline report referred to in G2 below eferenced in answering this question.)  PH HAS BEEN CHECKED TO SEE THAT WASTE IS IN COMPLIANCE
ON G.	PRETREATMENT
•	
s this	plant subject to an existing Pretreatment Standard?
s this	plant subject to an existing Pretreatment Standard?
s this 03.12? copy teport i	plant required to submit a baseline report per 40 CFR  NO If a baseline report has been prepared, attach to this questionnaire. Copy attached. If a baseline required, but has not yet been prepared, indicate date will be submitted.
s this 03.12? copy teport i hat it f subjecting me	plant required to submit a baseline report per 40 CFR  NO If a baseline report has been prepared, attach to this questionnaire. Copy attached If a baseline s required, but has not yet been prepared, indicate date
s this 03.12? copy teport i hat it f subjecting me	plant required to submit a baseline report per 40 CFR  NO If a baseline report has been prepared, attach to this questionnaire. Copy attached If a baseline s required, but has not yet been prepared, indicate date will be submitted  ect to Federal Pretreatment Standards, are the standards et on a consistent basis? (The baseline report can be
s this 03.12? copy teport i hat it f subjecting me	plant required to submit a baseline report per 40 CFR  NO If a baseline report has been prepared, attach to this questionnaire. Copy attached. If a baseline s required, but has not yet been prepared, indicate date will be submitted.  ect to Federal Pretreatment Standards, are the standards et on a consistent basis? (The baseline report can be to in answering this question.)
s this 03.12? copy teport i hat it f subjecting me	plant required to submit a baseline report per 40 CFR  NO If a baseline report has been prepared, attach to this questionnaire. Copy attached. If a baseline s required, but has not yet been prepared, indicate date will be submitted.  ect to Federal Pretreatment Standards, are the standards et on a consistent basis? (The baseline report can be to in answering this question.)
s this 03.12? copy teport i hat it f subjecting me	plant required to submit a baseline report per 40 CFR  NO If a baseline report has been prepared, attach to this questionnaire. Copy attached. If a baseline s required, but has not yet been prepared, indicate date will be submitted.  ect to Federal Pretreatment Standards, are the standards et on a consistent basis? (The baseline report can be to in answering this question.)

Are additional pretreatment facilities and/or operation and maintenance required to meet Pretreatment Standards? If additional pretreatment and/or operation and maintenance are required, list the schedule by which they will be provided. (The baseline report can be referred
to in answering this question.)  NA
Describe residuals (sludges, precipitates, etc.) that are produced or result at your facility and the methods employed to dispose of the residuals. List names of waste haulers, if applicable.
ANY GENERATED SLUDGES ARE REMOVED BY CERTIFIED
DEPOSES ACCORDING TO R.C.R.A. REQUIREMENTS AND

ASS LINE BURNET